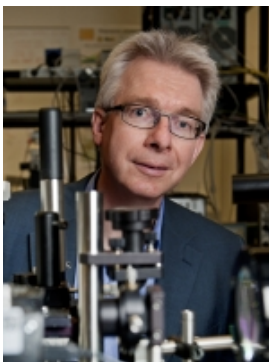


Albert Polman

Albert Polman is scientific group leader at the FOM Institute AMOLF in Amsterdam, the Netherlands, where he heads the Program “Light management in new photovoltaic materials”. He is professor of Photonic materials for photovoltaics at the University of Amsterdam. Polman obtained his Ph.D. from the University of Utrecht in 1989, was post-doctoral researcher at AT&T Bell Laboratories until 1991 and then became group leader at AMOLF, where he also served as director from 2006-2013. In 2003 he spent a sabbatical year at Caltech. Polman's research focuses on nanophotonics, with special emphasis on light management in solar cells and optical metamaterials. Polman is a co-founder of Delmic BV, a startup company that commercializes the angle-resolved cathodoluminescence imaging spectroscopy (ARCIS) technique developed by Polman and his group. Polman is member of the Royal Netherlands Academy of Arts and Sciences (KNAW), Fellow of the Materials Research Society (MRS), and recipient of an ERC Advanced Investigator Grant (2010), the ENI Renewable Energy Prize (2012), the Physica Prize of the Dutch Physical Society (2014) and the Julius Springer Award for Applied Physics (2014).



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